

Notice of Allowability	Application No.	Applicant(s)	
	10/544,216	KLOOTWIJK, JOHAN HENDRIK	
	Examiner	Art Unit	

Ori Nadav
2811

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--

All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. **THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS.** This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.

1. This communication is responsive to amendment filed on 05/03/2010.
2. The allowed claim(s) is/are 1-5 and 12-15.
3. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 - a) All b) Some* c) None of the:
 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

* Certified copies not received: _____.

Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.

THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.

4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.
 - (a) including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached
 - 1) hereto or 2) to Paper No./Mail Date _____.
 - (b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date _____.

Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.

Attachment(s)

1. Notice of References Cited (PTO-892)
2. Notice of Draftsperson's Patent Drawing Review (PTO-948)
3. Information Disclosure Statements (PTO/SB/08),
Paper No./Mail Date _____
4. Examiner's Comment Regarding Requirement for Deposit
of Biological Material
5. Notice of Informal Patent Application
6. Interview Summary (PTO-413),
Paper No./Mail Date 6/14/10.
7. Examiner's Amendment/Comment
8. Examiner's Statement of Reasons for Allowance
9. Other _____.

/Ori Nadav/
Primary Examiner, Art Unit 2811

DETAILED ACTION

Examiner's Amendment

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Robert Crawford on 06/14/2010.

The application has been amended as follows:

Claim 1, line 1, before "structure, comprising", delete "Trench isolation" and insert ---A semiconductor---

Claim 1, line 10, after "filling material," insert ---configured to provide trench isolation---

Claim 1, line 1, before "structure, comprising", delete "Trench isolation" and insert ---A semiconductor---

Claim 2, line 1, before "structure", delete "Trench isolation" and insert ---A semiconductor---

Claim 3, line 1, before "structure", delete "Trench isolation" and insert ---A semiconductor---

Claim 4, line 1, before "structure", delete "Trench isolation" and insert ---A semiconductor---

Claim 5, line 1, after "A", delete "trench"

Claim 5, line 2, before "structure", delete "isolation" and insert ---semiconductor---

Claim 12, line 1, after "A semiconductor structure", delete "providing trench isolation, the structure"

Claim 12, line 5, delete "a first insulating material"

Claim 12, line 8, before "first insulating material", delete "the" and insert ---a---

Claim 12, line 10, after "insulating material", insert ---for providing trench isolation and---

Reasons for allowance

The following is an examiner's statement of reasons for allowance:

Regarding claim 1, the claimed limitation of "wherein the liner is characterized by an abrupt increase in thickness, in at least a first part of the trench groove that is substantially in line with the buried layer" is understood to mean that the abrupt increase in thickness occurs in the part of the trench groove that is located substantially in the same horizontal line as that of the buried layer.

Regarding claim 12, the claimed limitation of "the first insulating material having a common thickness above and below the buried layer" is understood to mean that the first insulating material has the same thickness above and below the buried layer.

Thus, prior art do not teach or suggest, singularly or in combination, the entire claimed limitations.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ori Nadav whose telephone number is 571-272-1660. The examiner can normally be reached between the hours of 7 AM to 4 PM (Eastern Standard Time) Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Lynne Gurley can be reached on 571-272-1670. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

O.N.
7/9/2010

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PRIMARY EXAMINER
TECHNOLOGY CENTER 2800